

Form PTO-1449 INFORMATION DISCLOSURE CITATION IN AN APPLICATION (Use several sheets if necessary)	Document Number (Sequence) TSMC-02-1259	Application Number 10/671,293
	Applicant Chung-Hui Chen	
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U. S. PATENT DOCUMENTS

[illegible]

FOREIGN PATENT DOCUMENTS

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OTHER DOCUMENTS (Including Author, Title, Date, Pertinent Pages, Etc.)

✓	U.S. Patent App. Publication US 2002/0081832 A1 to Bernstein et al., Pub. Date 6/27/02, "Intralayer Decoupling Capacitor, Method of Manufacture and Testing Circuit of the Same".
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EXHIBIT

Jeffrey Zweizig

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